

**AMENDMENTS TO THE SPECIFICATION:**

Please replace the paragraph beginning on page 2, line 18, and ending on page 2, line 23, with the following amended paragraph:

In the field emission display taught by U.S. Patent No. 5,710,483, a second gate electrode is formed by deposition of a metal material. In a field emission display disclosed in Korean Patent No. 2000-7115 Laid Open No. 2001-0081496, a metal mesh, manufactured separately from a cathode plate and an anode plate, is bridged to the cathode plate and the anode plate via spacers provided between the anode plate and the cathode plate

Please replace the paragraph beginning on page 3, line 1, and ending on page 3, line 6, with the following amended paragraph:

On the other hand, in the case of the field emission display taught by Korean Patent No. 2000-7115 Laid Open No. 2001-0081496, a second gate electrode, i.e., a mesh grid, electrode is formed of a metal plate. Accordingly, unlike in U.S. Patent No. 5,710,483, there is no limit in the size of the second gate electrode. Rather, the thickness of the second gate electrode can be freely selected, and thus it is possible to effectively control electron beams.

Please insert the following new paragraph at page 6, line 5, after the heading BRIEF DESCRIPTION OF THE DRAWINGS:

The patent or application file contains at least one drawing executed in color. Copies of this patent or patent application publication with color drawing(s) will be provided by the Office upon request and payment of the necessary fee.